EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S10	2	"20050121326".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/08 10:42
S3	2	"20050121317".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/08 10:42
S11	2	"3498951".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR ,	ON	2007/05/08 11:31
S12	42	205/157.ccls. and copper and acid and "g/l"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/08 11:32
S13		205/157.ccls. and copper and acid and "g/l" and copper adj sulfate	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/08 11:34
S15	7	S14 and kalispell	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/08 11:35
S14	120	205/291.ccls. and copper and acid and "g/l" and copper adj sulfate	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/08 11:35
S2	4	calhoun.in. and ("204" "205").clas.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/08 13:02
S16	322	("204" "205").clas. and membrane and (semiconductor wafer microelectronic electronic microfeature) and anolyte and catholyte and acid	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/08 13:04

EAST Search History

						•
S17	193	("204" "205").clas. and membrane and (semiconductor wafer microelectronic electronic microfeature) and anolyte and catholyte and acid and copper	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/08 15:57
S19	102	S18 and anode and cathode and (semiconductor wafer electronic microelectronic microfeature)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/08 15:58
S18	192	("204" "205").clas. and (patterson sheridan) and membrane	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/08 15:58
S1 _.	117	concentric and dielectric and kalispell	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/09 10:27
S24	79	reid.in. and ("204" "205").clas.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/09 11:07